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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/775,351	02/10/2004	Warren M. Farnworth	2269-6105US(2003-0885.00/ 3156		
	7590 08/08/200 C, P.C./ MICRON TEC	EXAMINER			
P.O. BOX 2550)	KOCH, GEORGE R			
SALT LAKE CITY, UT 84110			ART UNIT	PAPER NUMBER	
			1791		
			NOTIFICATION DATE	DELIVERY MODE	
			08/08/2008	ELECTRONIC	

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

Notice of the Office communication was sent electronically on above-indicated "Notification Date" to the following e-mail address(es):

USPTOMail@traskbritt.com

Office Action Summary		Application	on No.	Applicant(s)				
		10/775,35	31	FARNWORTH, WARREN M.				
		Examiner		Art Unit				
		George R	Koch III	1791				
Period fo	The MAILING DATE of this communication Reply	on appears on the	cover sheet with the d	correspondence a	ddress			
WHIC - Exte after - If NC - Failu Any	ORTENED STATUTORY PERIOD FOR FOR HEVER IS LONGER, FROM THE MAILLI nsions of time may be available under the provisions of 37 of SIX (6) MONTHS from the mailing date of this communicat of period for reply is specified above, the maximum statutory re to reply within the set or extended period for reply will, by reply received by the Office later than three months after the department adjustment. See 37 CFR 1.704(b).	NG DATE OF TH CFR 1.136(a). In no evention. If period will apply and will If y statute, cause the app	IIS COMMUNICATION ent, however, may a reply be tir II expire SIX (6) MONTHS from ication to become ABANDONE	N. nely filed the mailing date of this of the (35 U.S.C. § 133).				
Status								
1) 又	Responsive to communication(s) filed on	08 May 2008						
-	This action is FINAL . 2b) ☐ This action is non-final.							
3)	· · · · · · · · · · · · · · · · · · ·							
٠,١	closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.							
Disposit	on of Claims							
4)⊠	Claim(s) 1-4 and 8 is/are pending in the	application.						
	4a) Of the above claim(s) is/are withdrawn from consideration.							
	Claim(s) is/are allowed.							
	6)⊠ Claim(s) <u>1-4 and 8</u> is/are rejected.							
	Claim(s) is/are objected to.							
-	Claim(s) are subject to restriction	and/or election re	equirement.					
	on Papers							
	• The specification is objected to by the Ex	aminer						
•	-		Objected to by the	Examiner				
.0/	10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.							
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a). Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).								
11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.								
,—	ınder 35 U.S.C. § 119							
	-	oreign priority up	der 35 II S.C. & 110/a	\-(d\ or (f\				
	12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).							
a)	a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received.							
	 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage 							
application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received.								
Oce the attached detailed Office action for a list of the certified copies flot received.								
Attachmen			л. П .	(DTO 410)				
	e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-9	48)	4) Interview Summary Paper No(s)/Mail D					
3) Information Disclosure Statement(s) (PTO/SB/08) 5) Notice of Informal Patent Application								
Paper No(s)/Mail Date <u>5/8/08</u> . 6) Other:								

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DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The text of those sections of Title 35, U.S. Code not included in this action can be found in a prior Office action.

2. Claims 1-3 and 8 are rejected under 35 U.S.C. 102(b) as being anticipated by Takamori (US 6,319,317 B1).

Takamori discloses system for selectively depositing a material on a previously formed workpiece, comprising a platform (Figure 4, item 52) for supporting the workpiece during a deposition process, a deposition system (item 86) configured to deposit the material on the workpiece to the specific thickness, and a sensing system (Figure 4, item 105) configured to measure over the semiconductor die both an upper surface including a previous material previously deposited thereon, the sensing system further configured to continuously directly measure in a dimension orthogonal to the platform a surface level during material deposition of the material on the upper surface according to direct measurements in the dimension substantially orthogonal to the platform until the surface level of the material is directly measured to be the specific thickness. (see, for example, column 12, lines 50-63). The sensor measures the "spreading state" and therefore is a continuous measurement system. The apparatus can operate on the claimed die and claimed surfaces. This measurement is considered to be a direct measurement in the context of applicant's direct measurement, which is measuring the surface data of the substrate and dispense by a transmitter and receiver (as described in applicant's own

specification 0042). The measurement is taking in a dimension substantially orthogonal to the platform (the sensor is positioned and aim in a straight line above the substrate.) Since Takamori is a sensor with a transmitter and receiver, and applicant's sensor is a transmitter and receiver, it anticipates the claim. Since the spreading state is directly proportional to the thickness, a measurement of spread is a measurement of thickness.

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This sensing system for measuring an upper surface is consider capable of measuring and upper surface over a semiconductor die including the upper sufarces and including a previous material previously deposited thereon. This apparatus in Takamori is considered capable of coating any type of substrate, including the claimed semiconductor die including a previous material previously deposited thereon.

As to claim 2, Takamori discloses that the deposition system is a spin-coating deposition system (see Figure 2, and especially claim 1, line 2, which discloses that the apparatus including "means for rotating a substrate").

As to claim 3, Takamori discloses that the sensing system includes a sensor (item 105) for both measuring the upper surface of the workpiece (prior to deposition) and for monitoring the surface level of the material deposited on the upper surface of the workpiece (during deposition). Takamori discloses measurement of the "spreading state" of the dispensed solution, which is a measurement of the before, during and after of the thickness or lack of it.

As to claim 8, Takamori discloses coating a semiconductor wafer (recited, for example, at column 1, line 10-11). Takamori is specifically directed to coating a semiconductor wafer with a resist film.

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Claim Rejections - 35 USC § 103

3. The text of those sections of Title 35, U.S. Code not included in this action can be found in a prior Office action.

4. Claims 1-3 and 8 are alternatively rejected under 35 U.S.C. 103(a) as being unpatentable over Takamori (US 6,319,317 B1) and Subramanian (US 6,270,579)

Takamori discloses system for selectively depositing a material on a previously formed workpiece, comprising a platform (Figure 4, item 52) for supporting the workpiece during a deposition process, a deposition system (item 86) configured to deposit the material on the workpiece to the specific thickness, and a sensing system (Figure 4, item 105) configured to measure over the semiconductor die both an upper surface including a previous material previously deposited thereon, the sensing system further configured to continuously directly measure in a dimension orthogonal to the platform a surface level during material deposition of the material on the upper surface according to direct measurments in the dimension substantially orthogonal to the platform until the surface level of the material is directly measured to be the specific thickness. (see, for example, column 12, lines 50-63). The sensor measures the "spreading state" and therefore is a continuous measurement system. The apparatus can operate on the claimed die and claimed surfaces. This measurement is considered to be a direct measurement in the context of applicant's direct measurement, which is measuring the surface data of the substrate and dispense by a transmitter and receiver (as described in applicant's own specification 0042). The measurement is taking in a dimension substantially orthogonal to the platform (the sensor is positioned and aim in a straight line above the substrate.) Since

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Takamori is a sensor with a transmitter and receiver, and applicant's sensor is a transmitter and receiver, it anticipates the claim. Since the spreading state is directly proportional to the thickness, a measurement of spread is arguably a measurement of thickness.

This sensing system for measuring an upper surface is consider capable of measuring and upper surface over a semiconductor die including the upper surfaces and including a previous material previously deposited thereon. This apparatus in Takamori is considered capable of coating any type of substrate, including the claimed semiconductor die including a previous material previously deposited thereon.

It can be argued that Takamori does not go as far as applicant does in defining the sensor techniques, especially with respect to how the sensor measures the thickness. However, Subramanian discloses further details of a sensor that monitors the surface and spreading state of a dispense. The sensor includes a transmitter (item 68) driven by light driver 66, which is directed towards the substrate surface and generates thickness uniformity data which is received by receiver 70 which feeds into measurement system 72 (see column 6, lines 31-59). This sensor directly measures a surface level of the material being deposited on the upper surface until the surface level of the material is directly measured to be a specific thickness of the material (as shown in step 210 of Figure 7, and see column 9, lines 30-35, which recites that "the processor 64 compares the measured thickness uniformity with the desired thickness uniformity, and determines whether or not the proper thickness uniformity has been achieved"). One in the art would appreciate that these techniques would further thickness uniformity. Therefore, it would have been obvious to one of ordinary skill at the time of the invention to have measured specifically the thickness in order achieve desired thickness uniformity.

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As to claim 2, Takamori discloses that the deposition system is a spin-coating deposition system (see Figure 2, and especially claim 1, line 2, which discloses that the apparatus including "means for rotating a substrate").

As to claim 3, Takamori discloses that the sensing system includes a sensor (item 105) for both measuring the upper surface of the workpiece (prior to deposition) and for monitoring the surface level of the material deposited on the upper surface of the workpiece (during deposition). Takamori discloses measurement of the "spreading state" of the dispensed solution, which is a measurement of the before, during and after of the thickness or lack of it.

As to claim 8, Takamori discloses coating a semiconductor wafer (recited, for example, at column 1, line 10-11). Takamori is specifically directed to coating a semiconductor wafer with a resist film.

5. Claim 4 rejected under 35 U.S.C. 103(a) as being unpatentable over Takamori OR Takamori and Subramanian as applied to claims 1-3 and 8 above, and further in view of Whitman (US 6,642,155).

As to claim 4, Takamori discloses measuring the upper surface of the workpiece and the surface level of the deposited material (see rejection of claim 3 above), but does not disclose using separate sensors for each function.

However, Whitman discloses that it is known in measuring the thickness during spin coating operations to utilize multiple sensors. Whitman uses to the multiple sensors to track coated and uncoated areas in order to properly coordinate the coating operation (as described in column 3). Therefore, it would have been obvious to one of ordinary skill in the art at the time

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of the invention to have utilized such sensors in order to achieve coordination of the coating operation.

Response to Arguments

6. Applicant's arguments with respect to claims 1-4 and 8 filed 12/19/2007 have been considered but are unpersuasive. Much of the arguments overlap with prior arguments and are unpersuasive for the same reasons given in the actions mailed 2/8/2008, 7/31/2007, 5/2/2007, 9/21/2006, etc. Most of applicants arguments are devoted to things the apparatus invention does, not the structure of the apparatus itself. "Configured to deposit" material is merely a statement of intended used.

Additionally, the measurement in Takamori are taken in a dimension substantially orthogonal to the platform (the sensor is positioned and aim in a straight line above the substrate.) (See figures, and the relative positions of item 105 and the substrate/wafer)/

Takamori is considered to be directly measuring, which is considered to be an intended use step that Takamori is considered capable of performing. A recitation of the intended use of the claimed invention must result in a structural difference between the claimed invention and the prior art in order to patentably distinguish the claimed invention from the prior art. If the prior art structure is capable of performing the intended use, then it meets the claim.

7. Additionally, Subramanian has been applied to show that the particular sensor system as described in applicant's specification is known.

Conclusion

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8. **THIS ACTION IS MADE FINAL.** Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to George R. Koch III whose telephone number is (571) 272-1230 (TDD only). If the applicant cannot make a direct TDD-to-TDD call, the applicant can communicate by calling the Federal Relay Service at 1-866-377-8642 and giving the operator the above TDD number. The examiner can normally be reached on M-F 9-5.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Philip Tucker can be reached on (571) 272-1095. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent

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/George R. Koch III/ Primary Examiner, Art Unit 1791

7/31/2008